

Economical Manufacture of Seamless High-Purity Niobium

Ultramet
(Materials and Structures)
V.M. Arrieta, S.R. McNeal

Oak Ridge National Laboratory
(Characterization)
D. Christen

Niowave
(SRF Technology Consultant)
T. Grimm

DOE Office of Nuclear Physics
(Program Official)
L.K. Len

Goal/Approach

The technical objective of this project was to develop an efficient, cost-effective means of fabricating seamless ultrahigh-purity niobium superconducting radio frequency (SRF) cavities suitable for particle accelerator applications. The focus of the work was on optimizing chemical vapor deposition (CVD) niobium processing to deposit structural high-purity (RRR300 or better) niobium.

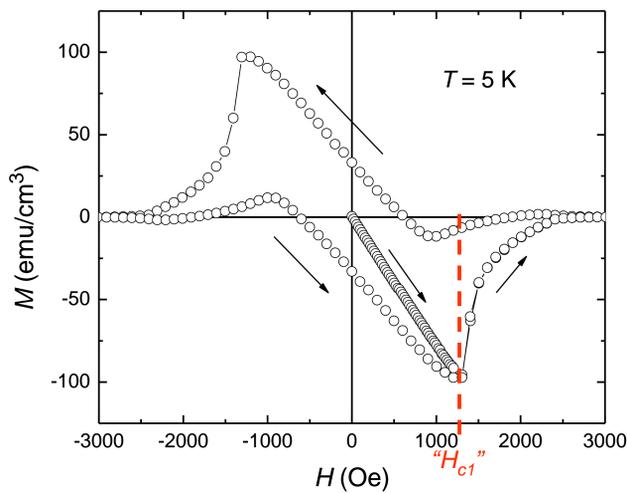


Figure 1: Gradient Performance Potential
Complete magnetization loop at 5 K for tested sample, showing H_{c1} (field of first significant flux penetration) at ~ 1300 Oe and H_{c2} at high field to be ~ 2750 Oe

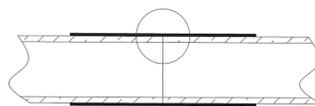
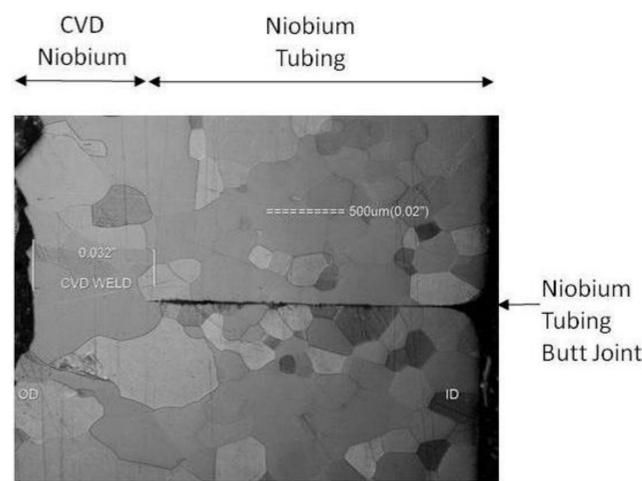


Figure 2: CVD Joining
Micrograph and schematic of CVD-welded tensile test specimen (butted Nb tubes with CVD Nb weld, ~ 0.030 " thick). Measured ultimate tensile strength was 39.327 ksi, vs. reported strength of pure annealed niobium = 43.5 ksi

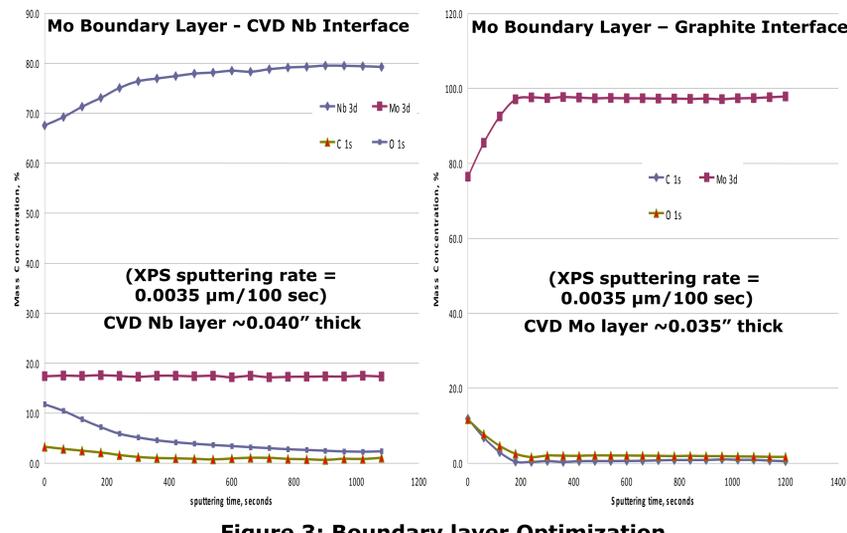


Figure 3: Boundary Layer Optimization
XPS analysis of Mo/CVD Nb interface (left) and Mo/graphite interface (right) showing mass concentration (%) vs. sputtering time (sec)

The XPS results in Figure 3 verify that a significant percentage of the impurities present in the CVD niobium test specimens following mandrel removal were confined to the surface of the material to a depth of less than ~ 0.035 μm .

Summary

The niobium material optimization conducted in this project, combined with the demonstration of near-net-shape cell prototype fabrication performed in earlier work, continue to support further development of this innovative approach to the fabrication, joining, modification, and repair of SRF accelerator components.

CVD niobium was deposited under various conditions to maximize purity using a relatively low-cost, moderate-purity niobium starting material, and resistance and magnetic properties were characterized. Impressive RRR values up to 282 were measured in testing at ORNL.

The initial feasibility of using the CVD process to join prefabricated niobium components, as a means to reduce or eliminate expensive electron beam welding, was demonstrated, and preliminary development of a low-cost mandrel for cavity fabrication in a production environment was performed.

Demonstration Component: Seamless CVD Niobium Cell

(Produced in previous DOE-funded research)



As-Deposited CVD Niobium (with graphite mandrel)

CVD Niobium Cell Structure (mandrel removed, OD polished)

>RRR200 CVD Nb Potential Applications:

- Fabrication
- Joining
- Modification
- Repair